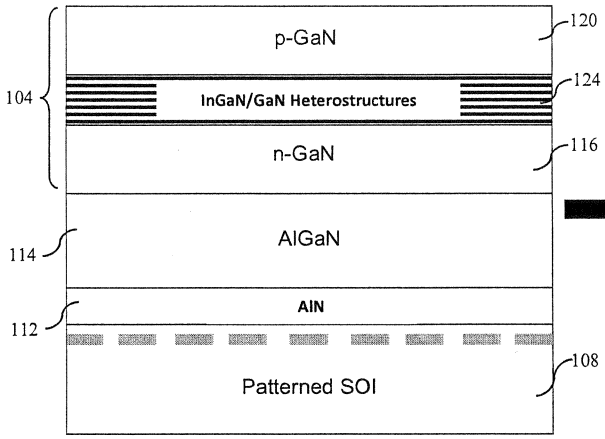


FIG. 1A

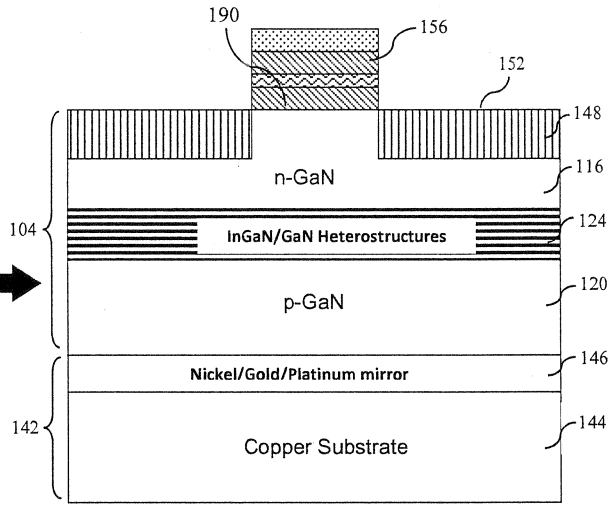


FIG. 1B

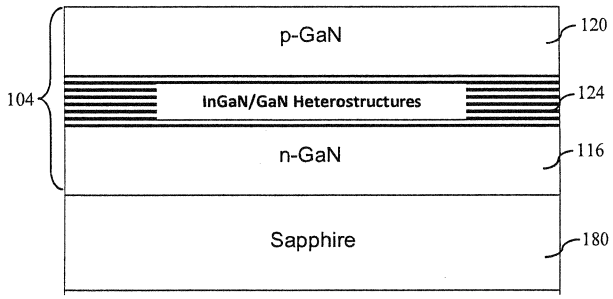


FIG. 1C

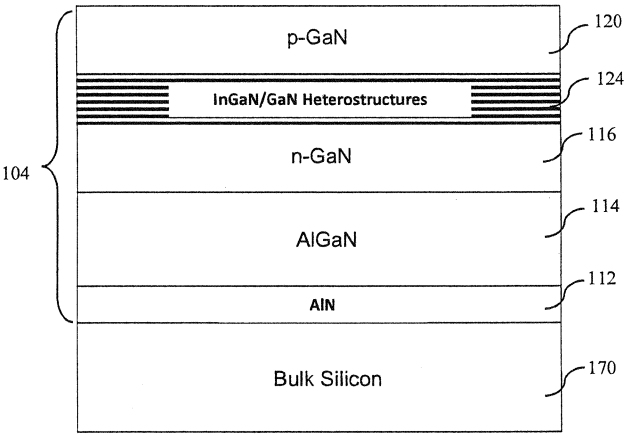


FIG. 1D

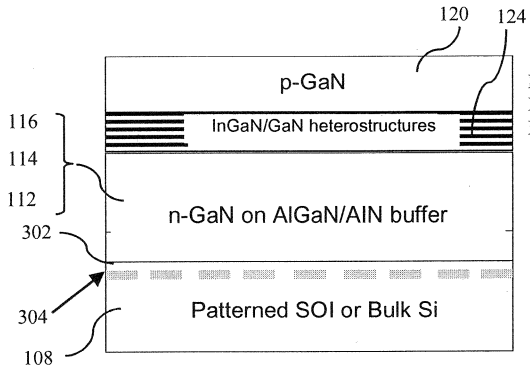


FIG. 3A

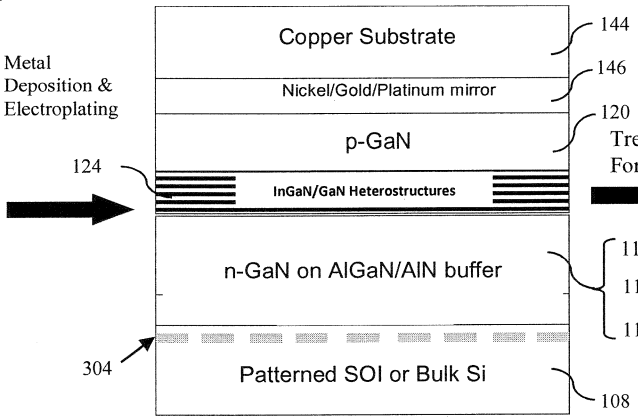
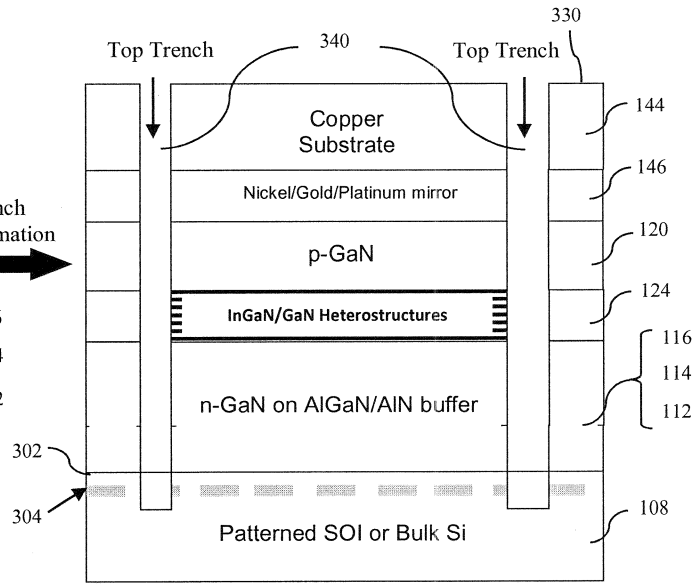


FIG. 3B



or

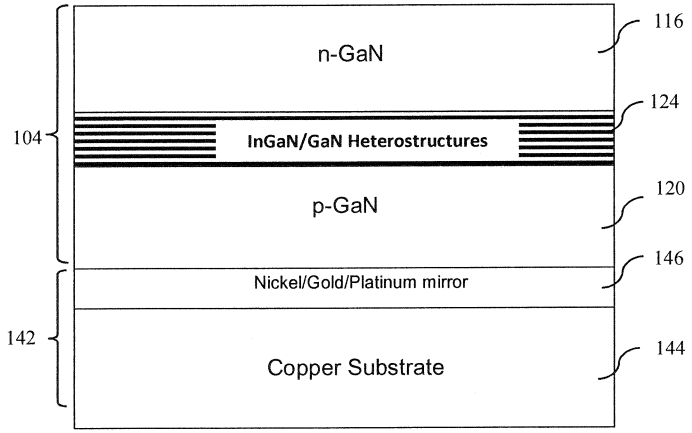


FIG. 3D

Dry Lift-Off

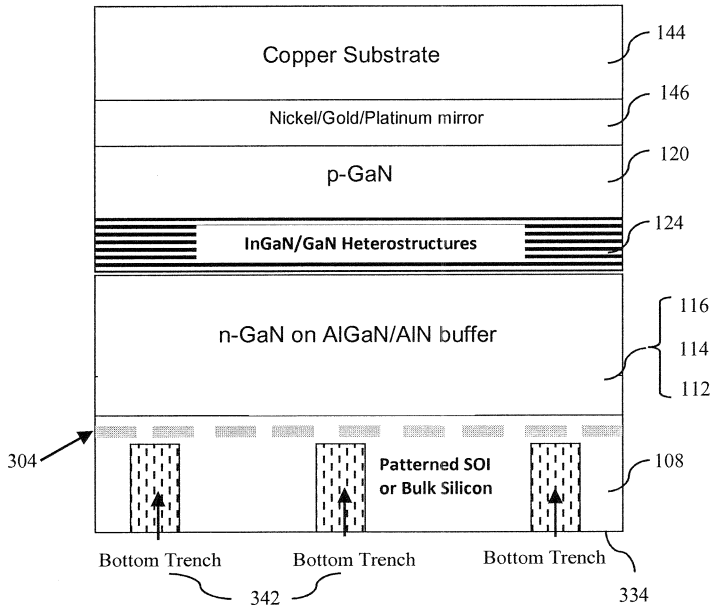


FIG. 3C

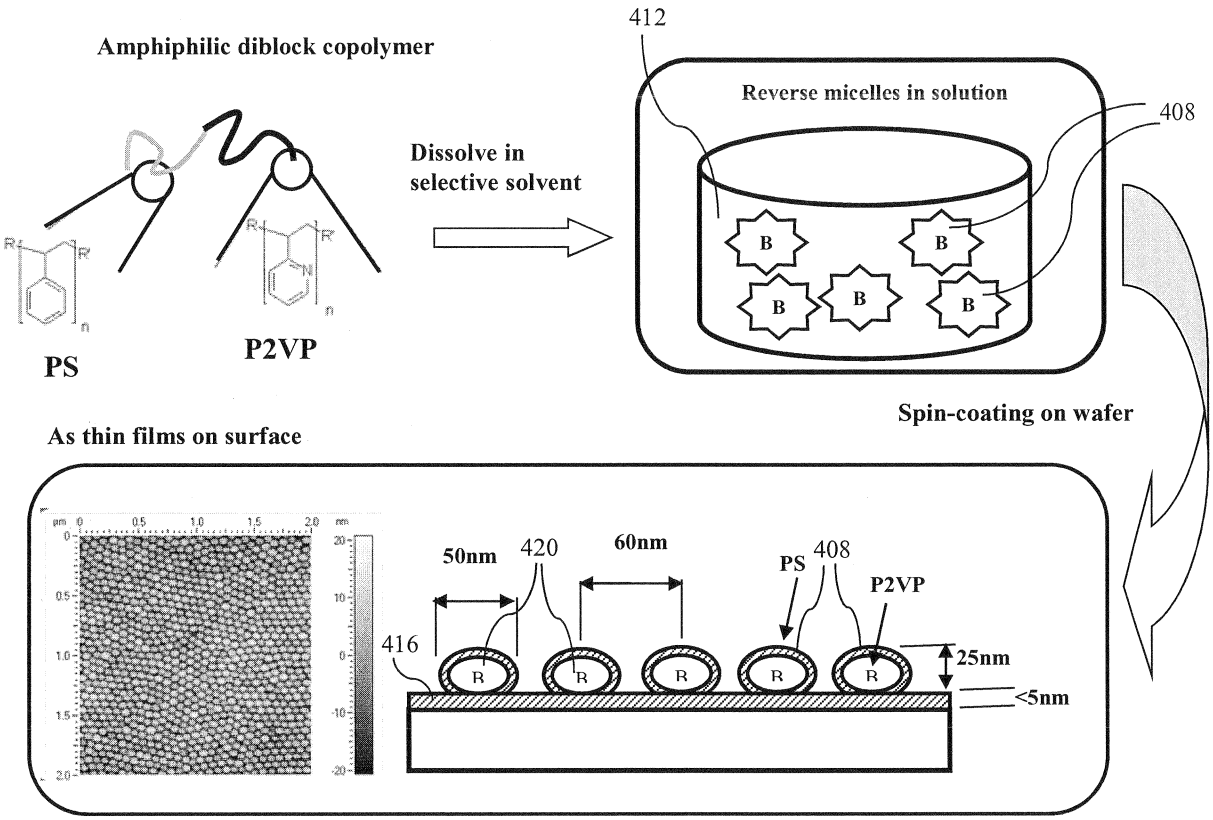

Amphiphilic diblock copolymer
PS
P2VP
Dissolve in
selective solvent
412
Reverse micelles in solution
408
B
Spin-coating on wafer
As thin films on surface
50nm
420
60nm
PS
408
P2VP
416
25nm
<5nm

FIG. 4

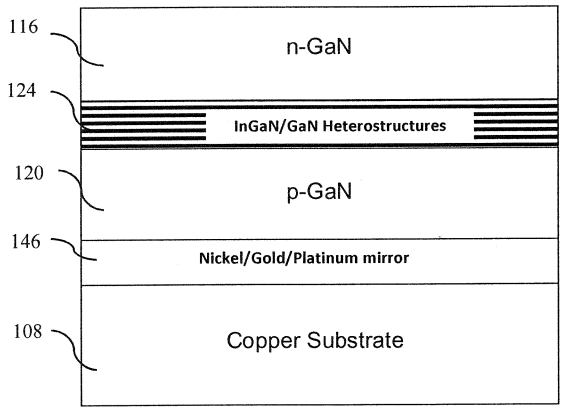


FIG. 5A

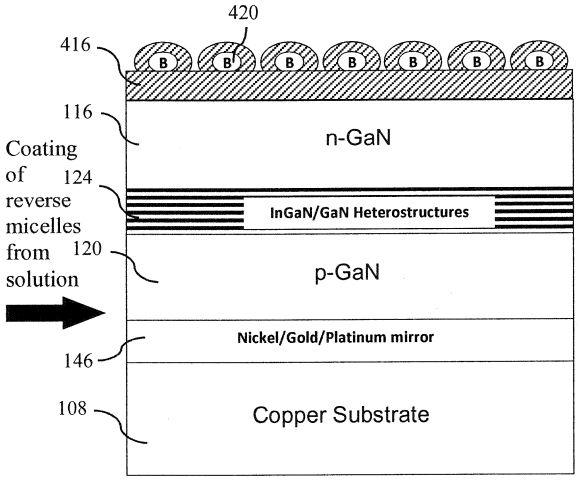


FIG. 5B

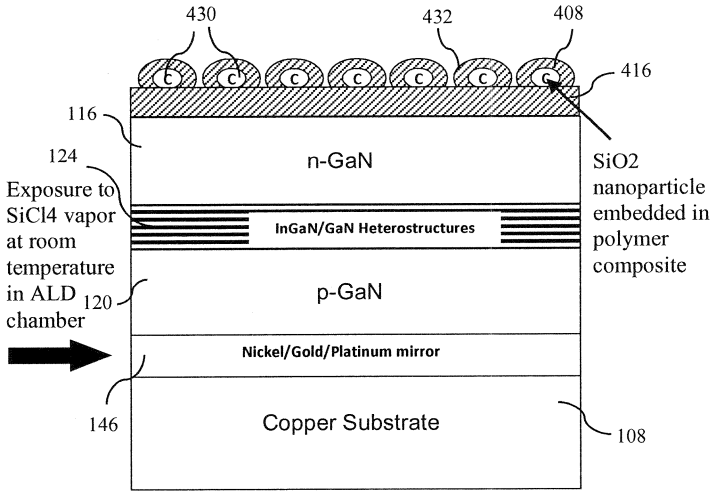


FIG. 5C

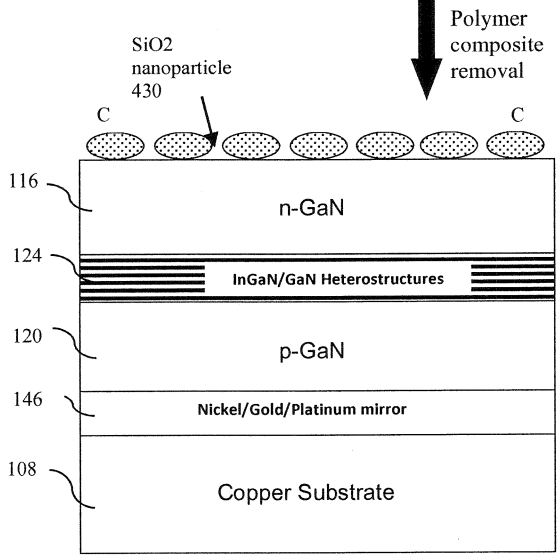


FIG. 5D

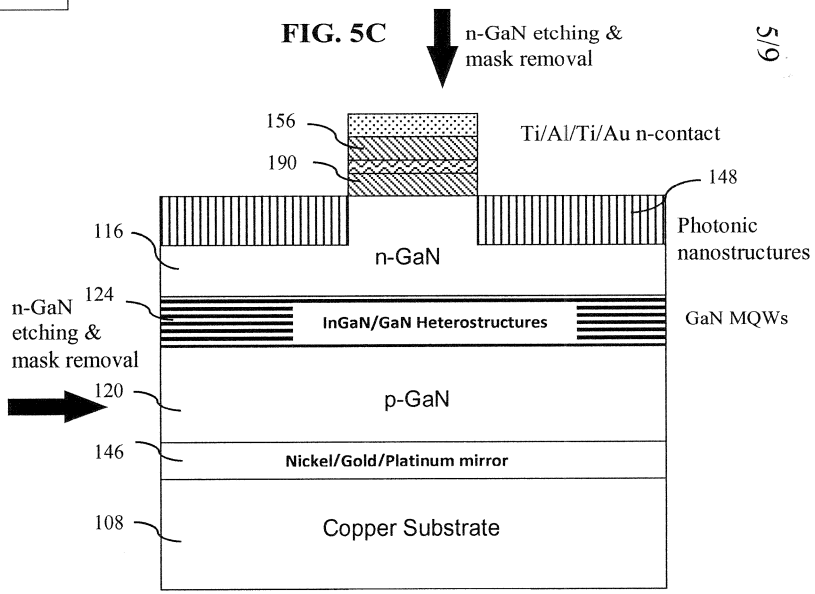


FIG. 5E